

Novel Inorganic Rings and Materials Deposition

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Plan for the Lecture

'Using Chemistry to Control Material Deposition: why choose to use a chemical method ?'

Introduction- the inorganic ring systems we have studied

- Dichalcogenoimidodiphosphinates
- •An Introduction to CVD
- •Dithio and Diseleno-phosphinates
- •New routes to selenohosphinates
- •CIGS systems
- Shapes of nanoparticles

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Ligands

- Dichalcogenoimidodiphosphinates
- Dichalcogenophosphinates





 $R = {}^{I}Pr$, Ph, ${}^{t}Bu$; E = S, Se





R = Pr, Ph; E = Se

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Dichalcogenoimidodiphosphinate Ligands



- a) A. Schmidpeter, H. Groeger, Z. Anorg. Allg. Chem. 1966, 345, 106.
- b) G. G. Briand, T. Chivers and M. Parvez, Angew. Chem. Int. Ed., 2002, 41, 3468.
- c) M. Ellermann, M. Schtz, F. W. Heinemann, M. Moll, Z. Anorg. Allg. Chem. 1998, 624, 257.
- d) D. Cupertino, D. J. Birdsall, A. M. Z. Slawin, J. D. Woollins, Inorg. Chim. Acta, 290, 1, 1999.







M = Cd







S. S. Garje, M. Capsey, M. Afzaal, P. O'Brien, and T. Chivers, J. Mater. Chem. submitted.



C(21



Cu(2)

Sel4

C(27

Cu(3)

C(35)

C(32)

Se(5)



Dalton Transactions 2003, 1500-1504; J. Mater. Chem., 2004, 14, 233.





where $R = {}^{i}Pr$ or Ph and M = Cd, Zn or Hg



- Efficient synthesis of *"air-stable"* M [N(SePR₂)₂]₂ (yields 95-99%).
- Reaction can be scaled up (~25g) without loss to quality/yield.
- *"Dot"* synthesis is convenient and efficient.



PL of CdSe by Thermolysis of Cd[N(SePⁱPr₂)₂]₂

D.J.Crouch, P. O'Brien, M.A.Malik, P.J.Skabara and S.P. Wright, Chem. Commm., 2003 1454.

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Low-pressure CVD







What makes for a good precursor?

- Volatility
- Clean decomposition
- Stability under delivery conditions
- Compatibility with other precursors
- Freedom from adventitious impurities

Conventional route

- Highly toxic and/or oxygen or moisture sensitive gases *e.g.* H₂S, H₂Se, NH₃, PH₃, AsH₃, SiH₄ etc.
- Environment and safety conditions: particularly important for industrial processes.





M = Cd(1), X = I; M = Hg(2), X = Cl, tmeda = tetramethylethanediamine



Fig. 1 Thermal ellipsoid plot (30% probability) of the structure of 2a (M = Zn), 2b (M = Cd) and 2c (M = Hg). Hydrogen atoms have been omitted for clarity.

Synthesis and structures of M[N(TePPrⁱ₂)₂-*Te*, *Te*']_n (n = 2, M = Zn, Cd, Hg; n = 3, M = Sb, Bi): the first ditelluroimidodiphosphinato p- and d-block metal complexes

Tristram Chivers,* Dana J. Eisler and Jamie S. Ritch

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SEM of (a) CdTe and Te deposited at 375°C;

CdTe deposited at (b) 425°C, (c) 475°C; (d) HRTEM of film deposited at 475°C.



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Cubic CdTe marked with asterisk and Hexagonal Te film

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films grown by LP-MOCVD of Bi[$(SeP'Pr_2)_2N]_3$ at (a) $T_{prec} = 275 \text{ °C}, T_{subs} = 425 \text{ °C},$ (b) $T_{prec} = 225 \text{ °C}, T_{subs} = 425 \text{ °C},$ (c) $T_{prec} = 225 \text{ °C}, T_{subs} = 400 \text{ °C},$ (d) $T_{prec} = 225 \text{ °C}, T_{subs} = 375 \text{ °C}.$

Dalton Transactions 2003, 1500-1504



J.-Ho Park, M. Afzaal, M. Helliwell, M. A. Malik, P O'Brien, and J. Raftery, Chem. Mater. 15, 2003, 4205.



AACVD studies of Sb[(TePⁱPr₂)₂N]₃

• pXRD of rhombohedral Sb₂Te₃ thin films at 475 °C with a dynamic argon flow rate of 240 sccm.



S. S. Garje, D. J. Eisler, J. S. Ritch, M. Afzaal, P. O'Brien, and T. Chivers, J. Am. Chem. Soc, 2006, 128, 3120.







AACVD from $\{\ln(\mu-Te)[N(^{i}Pr_2PTe)_2]\}_3$



S. S. Garje, M. Capsey, M. Afzaal, P. O'Brien, and T. Chivers, J. Mater. Chem. submitted.







Micrograph of rhobohedral Sb_2Se_3 grown on glass at (a) 400 °C (b) 425 °C (c) 450 °C (d) 475 °C from (b) $[Sb(Se_2P'Pr_2)_3]$ with an Ar flow rate of 180 sccm

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b) C. Byrom, M.A. Malik, P. O'Brien, A.J.P. White, D.J. Williams, Polyhedron, 19, 2000, 211.





C. Byrom, M.A. Malik, P. O'Brien, A.J.P. White, D.J. Williams, Polyhedron, 19, 2000, 211.

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A Serendipitous Synthesis of Diselenophosphinates



 $\mathbf{R} = {}^{\mathbf{i}}\mathbf{P}\mathbf{r}$





Expected Product



HOWEVER!



Obtained Product



Possible Mechanism?

Main Product



Inserting of Se into P-Si bond of the intermediate R₂PSi(Me)₃?

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Novel Synthetic Route to Se Phosphinates



Q. C. Nguyen, M. Mohammad, M. A. Malik, P. O'Brien, Chem. Commun., 2006, 2179.





(^{*i*}Pr₂PSe)₂Se

(Ph₂PSe)₂Se





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X-ray Crystal Structures



Inorganic complexes



C. Q. Nguyen, M. Afzaal, M. A. Malik, P. O'Brien, Chem. Commun., 2006, 2182.



DIALKYLDICHALCOGENOPHOSPHINATES

Previous Work



Unstable, never isolated, used *in situ* to make metal complexes, no solid state characterization

References: (a) J. Inorg. Nucl. Chem. 1974, **36**, 472-5; (b) Angw. Chem. 1969, 8, 89. (c) Polyhedron 1991, 10, 2641.



A New Route to R₂PSe₂ Ligands

Alternatively, use excess Lewis Base NEt₃ to stabilize

ionic species e.g. [(ⁱPr)₂PSe₂]⁻

- HSiCl₃/NEt₃ : did not work due to the formation of [HNEt₃⁺][SiCl₃⁻]
- HSiEt₃/NEt₃ : worked



 $R = {}^{i}Pr, Ph, {}^{t}Bu$



X-ray Crystal Structures



(HNEt₃)(ⁱPr₂PSe₂)



 $(^{t}Bu_{2}PSe_{2})$

Disorder in the cation hence, not shown





 $(HNEt_3)(Ph_2PSe_2)$

(HNEt₃)(ⁱPr₂PSSe)



Inorganic complexes



 $[Ga(Ph_2PSe_2)_3]$



 $[Pb(Se_2P^iPr_2)_2]$



 $[Zn(^{t}Bu_{2}PSe_{2})_{2}]$



 $[Ag_4(SSeP^iPr_2)_4]$

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Thin-film solar cells based on CIGS (Cu(In,Ga)Se₂) companies working with CIGS cells include Shell Solar and Würth.

Early Honda CIGS module prototypes had a maximum output of 112 W at dimensions of $1,367 \times 802 \times 46$ mm.

http://www.speedace.info/automotive_directory/honda.htm





CIGS Coming Down to Earth









Copper complexes

From CuCl

4 (HNEt₃)(ⁱPr₂PSe₂) + 4 CuCl \longrightarrow {(ⁱPr₂PSe₂)Cu}₄ + 4 (HNEt₃)Cl

From CuCl₂

8 (HNEt₃)(ⁱPr₂PSe₂) + 4 CuCl₂ $\xrightarrow{\text{MeOH}}$ {(ⁱPr₂PSe₂)Cu}₄ + 8 (HNEt₃)Cl + 2 (ⁱPr₂PSe)₂Se₂

Cu(II) is reduced to Cu(I) by the ligand



NMR of Copper complexes



X-ray Structure of Copper complex

AA-CVD Experiments: Solvent: toluene; Flow rate: 160 sccm; Time: 90 mins; Substrate: Glass

AA-CVD Experiments: Solvent: toluene; Flow rate: 160 sccm; Time: 90 mins; Substrate: Glass; Stoichiometric Cu:In ratio

And also Nanoparticles

Nanoco's Technology

illuminating the future

High resolution electron microscope Image of single QD (5nm across)

Electron microscope image showing QD In very ordered patern

30 grams of 560nm QD. No other company in the world can produce this quantity. Market value in today's bio applications greater than \$10Million. Competitors can only produce 100 milligrams, 300X less material per batch. Nanoco will soon be producing 1 kilo batches

ZnSe nanoparticles from [Zn(Se₂PⁱPr₂)₂]

Hexadecylamine (HDA) capped hexagonal ZnSe nanoparticles grown at 300 °C for 30 min from (a) 0.2 g, (b) 0.4 g and (c) 0.6 g of precursor.

Emission Spectra

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a = 375 nm (3.30 eV)
b = 414 nm (2.99 eV)
c = 418 nm (2.96 eV)
Vs.
Bulk ZnSe = 459 nm (2.79 eV)
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TEM image of ZnSe nanomaterial

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N = 3

Total atoms = 10 Surface atoms = 10

Total atoms = 27 Surface atoms = 26

Shape	Total atoms	Surface atoms
Cube Bcc packing	$(N+1)^3 + N^3$	$6N^2 + 2$
Cube Fcc packing	$4N^3 + 6N^2 + 3N + 1$	$12N^{2}+2$
Octahedron Fcc packing	$\frac{2N^3}{3} + \frac{N}{3}$	$4N^2-8N+6$
Tetrahedron Fcc packing	$\frac{N^3}{6} + \frac{N^2}{2} + \frac{N}{3}$	$2N^2-4N+4$
Cuboctahedron triangular faces, fcc packing	$\frac{10N^3}{3} - 5N^2 + \frac{11N}{3} - 1$	10N ² -20N+12

Relationship between the number of shells N and the total number of atoms and surface atoms for different shapes

P. John Thomas and P. O'Brien J. Amer. Chem. Soc., 128, 2006 5615-5615

Plot showing the changes in the surface atom percentage (SAP) accompanying the growth of four hexagonal branches. The dotted line represents the SAP profile that the seed would have adopted if branching had not taken place.

:Plot showing changes in the maximum difference in the surface atom percentage (Δ SAPmax) between the tetrahedron and the corresponding structures with four hexagonal branches grown from a CdSe seed.

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And FinallySome Thanks

Thanks

- •EPSRC •RCUK
- University of Manchester
- Mohammed Afzaal
- Chin Ngyuan
- •Azad Malik
- •Colin Byrom
- Shivram Garj (Boyscast)

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5th Floor Materials and Magnets 2002/03 (SRIF)

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